Form PTO-1449 (REV. 8-83)	US Dept. of Commerce PATENT & TRADEMARK OFFICE	ATTY DOCKET NO. 119144	APPLICATION NO. New U.S. Patent Application
INFORMATION DISCLOSURE STATEMENT (Use several sheets if necessary)		APPLICANT Etienne QUESNEL	
		FILING DATE March 18, 2004	

U.S. PATENT DOCUMENTS

EXAMINER INITIAL		DOCUMENT NUMBER	DATE	NAME	CLASS	SUB CLASS
	1	US 6,396,900 B1	5/28/2002	BARBEE et al.		
	2	5,310,603	5/10/1994	FUKUDA et al.		

FOREIGN PATENT DOCUMENTS

		DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUB CLASS

OTHER DOCUMENTS (Including Author, Title, Date, Pertinent Pages, etc.)

	3	DRÛSEDAU et al. "THE HYDROGENATED AMORPHOUS SILICON/NANODISPERSE METAL (SIMAL) SYSTEM - FILMS OF UNIQUE ELECTRONIC PROPERTIES," Journal of Non-Crystalline Solids 198-200 (1996) 829-832.
	4	KIM et al. "ANNEALING EFFECTS ON a-SiC:H AND a-SiC:H(F) THIN FILMS DEPOSITED BY PECVD AT ROOM TEMPERATURE," Thin Solid Films 261 (1995) 192-201.

EXAMINER	DATE CONSIDERED
	4/29/05

Examiner: Initial if citation considered, whether or not citation is in conformance with M.P.E.P. 609; draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.

Date: March 18, 2004